NOTES:

1. SUBSTRATE:

FUSED SILICA

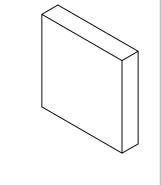
2. COATING (APPLY ACROSS CLEAR APERTURE)

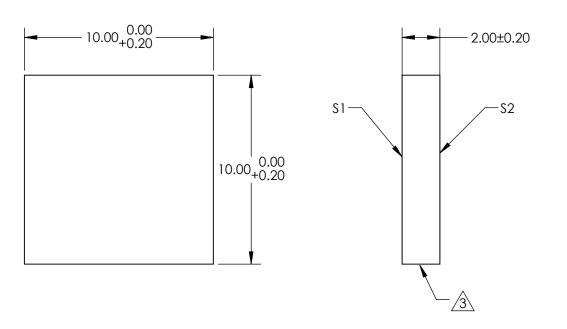
\$1:DIELECTRIC MIRROR (750-1100nm) R(AVG) >98% @ 750 - 1100nm @ 0 - 45° AOI R(AVG) >99% @ 750 - 1100nm @0° AOI

S2: NONE

3. FINE GRIND SURFACE (ADD INK NOTE AS NEEDED)

4. ROHS COMPLIANT





FOR INFORMATION ONLY: DO NOT MANUFACTURE PARTS TO THIS DRAWING

SPECIFICATIONS SUBJECT TO CHANGE WITHOUT NOTICE DIMENSIONS ARE FOR REFERENCE ONLY

SHAPE	S1 PLANO	S2 PLANO			Edmund Optics®
CLEAR APERTURE (%) SURFACE QUALITY	90 20 - 10	N/A COMMERCIAL POLISH	THIRD ANGLE PROJECTION	TITLE	10 x 10mm, 750 - 1100nm Broadband λ/10 Mirror
SURFACE FLATNESS	λ/10	N/A			
BEVEL	PROTECTED AS NEEDED	PROTECTED AS NEEDED	ALL DIMS IN mm	DWG NO	29925 SHEET 17 OF 2